PATENT IBM/319

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants: Toshiharu Furukawa, et al. Confirmation No. 5763

Serial No.: 10/711,764
Filing Date: October 4, 2004
Examiner: Jarrett J. Stark

Art Unit: 2823

Title: LOW-K DIELECTRIC LAYER BASED UPON CARBON

NANOTUBES (formerly entitled LOW-K DIELECTRIC MATERIAL

BASED UPON CARBON NANOTUBES)

Atty. Docket No.: BUR920040152US1

AMENDMENT UNDER 37 C.F.R. § 1.111

Mail Stop AMENDMENT Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

In reply to the non-final Office Action dated August 11, 2006, please amend the aboveidentified application as follows:

Amendments to the Claims are reflected in the listing of claims that begins on page 2 of this paper.

Remarks begin on page 5 of this paper.